Abstract of the invention

A process and a device for the galvanic surface treatment of work pieces are disclosed. The device comprises a closed process chamber wherein a work piece is received, the work piece having at least one surface exposed toward the process chamber. A process fluid is fed via inlet openings into the process chamber and is removed via outlet openings from the process chamber. At least one electrode is provided that is connected to a DC power source, while the work piece is connected to the opposite pole of the power source. The process fluid is pumped through the process chamber along a surface to be treated, while a plurality of inlet openings and outlet openings are arranged in an alternating configuration in a common surface opposite the treatment surface.